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	Application No.	Applicant(s)	_
Notice of Allowability	09/956,890	OCHIAI ET AL.	
	Examiner	Art Unit	
	Satya B Sastri	1713	
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT F of the Office or upon petition by the applicant. See 37 CFR 1.31	S (OR REMAINS) CLOSED in i) or other appropriate comm RIGHTS. This application is a	n this application. If not include unication will be mailed in due c	d ourse. THIS
1. $igwedge$ This communication is responsive to <u>amendment filed on</u>	January 20, 2004.	•	
2. ☑ The allowed claim(s) is/are <u>1-4 and 8</u> .			
3. The drawings filed on are accepted by the Examin	er.		
 4. ☐ Acknowledgment is made of a claim for foreign priority unally a) ☐ All b) ☐ Some* c) ☐ None of the: 1. ☐ Certified copies of the priority documents have a. ☐ Certified copies of the priority documents have a. ☐ Copies of the certified copies of the priority documents have a linternational Bureau (PCT Rule 17.2(a)). * Certified copies not received: 	re been received. re been received in Application	on No	on from the
Applicant has THREE MONTHS FROM THE "MAILING DATE noted below. Failure to timely comply will result in ABANDON THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	" of this communication to file MENT of this application	e a reply complying with the req	uirements
5. A SUBSTITUTE OATH OR DECLARATION must be sub- INFORMAL PATENT APPLICATION (PTO-152) which give	nitted. Note the attached EX ves reason(s) why the oath o	AMINER'S AMENDMENT or NO r declaration is deficient.	OTICE OF
 CORRECTED DRAWINGS (as "replacement sheets") musical including changes required by the Notice of Draftspe including changes required by the Notice of Draftspe to Paper No./Mail Date (b) including changes required by the attached Examine Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR each sheet. Replacement sheet(s) should be labeled as such in 	rson's Patent Drawing Revie r's Amendment / Comment o	r in the Office action of the drawings in the front (not the	back) of
 DEPOSIT OF and/or INFORMATION about the dep attached Examiner's comment regarding REQUIREMENT 	osit of BIOLOGICAL MAT	ERIAL must be submitted. N	ote the
Attachment(s)	e Managara en	oformal Datant Application (DTC	152\
1. Notice of References Cited (PTO-892)	_	nformal Patent Application (PTC	- 132)
2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	Paper No	Summary (PTO-413), /Mail Date	•
 Information Disclosure Statements (PTO-1449 or PTO/SB Paper No./Mail Date 	/08), 7. ☐ Examiner's	: Amendment/Comment	
 Examiner's Comment Regarding Requirement for Deposit 		Statement of Reasons for Allow	wance
of Biological Material	9. 🔲 Other	·	

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DETAILED ACTION

1. This office action is in response to the amendment filed on January 20, 2004. With the cancellation of *claims 7, 9, 10* in the amendment, *claims 1-4, 8* are now pending in the application. In view of the amendment of claims, rejection of *claims 1-4, 8* under 35 U.S.C. 103(a) as being unpatentable over Uchiumi et al. (US 6,329,480 B1) is withdrawn. Additionally, the 1.132 Declaration submitted by the Applicants is deemed persuasive and distinguishes the claimed invention from the prior art used for rejection in earlier office actions.

Allowable Subject Matter

2. Claims 1-4, 8 are allowed.

The following is an examiner's statement of reasons for allowance:

The present claims are allowable over the closest reference to Uchiumi et al. (US 6,329,480 B1).

The present invention discloses a process for producing poly(meth)acrylate having a reduced metal content and in which a bound site to (meth)acrylic acid is a tertiary carbon or in which said site is an acetal, which comprises contacting a mixture of a (poly)methacrylate in which a bound site to (meth)acrylic acid is a tertiary carbon or an acetal and an organic solvent with an acidic aqueous solution obtained by dissolving oxalic acid in water.

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Uchiumi et al. disclose the process for the preparation of acrylic acid ester polymer that includes carrying out polymerization of an acrylic acid ester or block copolymerization of an acrylic acid ester and another (meth)acrylic monomer in the presence of an organometallic compound. Uchiumi et al. further disclose that for the removal of the metal compound, it is effective to subject the acrylic acid ester polymer to cleaning treatment such as washing treatment such as washing treatment with an acidic aqueous solution. Additionally, Uchiumi et al. include that it is preferred to wash the acrylic acid ester polymer with an acidic aqueous solution as soon as possible after the termination of the polymerization, whereby metal components can be removed with high efficiency. In as far as the acidic aqueous solutions are concerned, the prior art includes acids such as hydrochloric acid, sulfuric acid, nitric acid, acetic acid, propionic acid, and citric acid (column 18, lines 15-30). The prior art does not include oxalic acid as disclosed in the instant invention. Additionally, applicant's show comparative results that accounts from unexpected low levels of metal content as compared to other acids disclosed in the prior art.

Therefore, the instantly claimed invention is deemed allowable over the closest prior art of record as per said art neither anticipating nor rendering obvious the instantly claimed process for producing poly(meth)acrylate having a reduced metal content and in which a bound site to (meth)acrylic acid is a tertiary carbon or in which said site is an acetal, which comprises contacting a mixture of a (poly)methacrylate in which a bound site to (meth)acrylic acid is a tertiary carbon or

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an acetal and an organic solvent with an acidic aqueous solution obtained by dissolving oxalic acid in water. There is no teaching or suggestion or motivation to modify the prior art method to include all the processing limitations disclosed in the instant invention.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

3. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Satya Sastri at (571) 272 1112.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Wu can be reached at (571) 272 1114.

Any inquiry of a general nature or relating to the status of this application should be directed to the group receptionist at (703) 308-0661.

SATYA SASTRI

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February 10, 2004

2 July

DAVID W. WU SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 1700